



DOI: 10.1038/s41467-018-07297-5

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Author Correction: Atomically precise graphene etch stops for three dimensional integrated systems from two dimensional material heterostructures

Jangyup Son¹, Junyoung Kwon², SunPhil Kim¹, Yinchuan Lv³, Jaehyung Yu¹, Jong-Young Lee², Huije Ryu², Kenji Watanabe ⁴, Takashi Taniguchi⁴, Rita Garrido-Menacho^{3,5}, Nadya Mason^{3,5}, Elif Ertekin^{1,5}, Pinshane Y. Huang^{5,6}, Gwan-Hyoung Lee ² & Arend M. van der Zande^{1,5}

Correction to: *Nature Communications*; <https://doi.org/10.1038/s41467-018-06524-3>; published online 28 September 2018

The original version of this Article contained an error in the second sentence of the second paragraph of the ‘Electrical properties of fluorinated graphene contacts’ section of the Results, which incorrectly read ‘The mobility was calculated by the Drude model, $\mu = ne/\sigma$ where μ , n , e , and σ are the carrier mobility, carrier density, electron charge, and sheet conductivity, respectively’. The correct version states ‘ $\mu = \sigma/ne$ ’ in place of ‘ $\mu = ne/\sigma$ ’. This has been corrected in both the PDF and HTML versions of the Article.

Published online: 20 November 2018



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¹ Department of Mechanical Science and Engineering, University of Illinois at Urbana-Champaign, 1206 W Green Street, Urbana, IL 61801, USA. ² Department of Materials Science and Engineering, Yonsei University, 50 Yonsei-ro, Seodaemun-gu, Seoul 03722, Korea. ³ Department of Physics, University of Illinois at Urbana-Champaign, 1110 W Green Street, Urbana, IL 61801, USA. ⁴ National Institute for Materials Science, 1-1 Namiki, Tsukuba, Ibaraki 305-0044, Japan. ⁵ Frederick Seitz Materials Research Laboratory, University of Illinois at Urbana-Champaign, 104 S Goodwin Avenue MC-230, Urbana, IL 61801, USA. ⁶ Department of Materials Science and Engineering, University of Illinois at Urbana-Champaign, 1304 W Green Street, Urbana, IL 61801, USA. Correspondence and requests for materials should be addressed to G.-H.L. (email: gwanlee@yonsei.ac.kr) or to A.Zande. (email: arendv@illinois.edu)